

<b>Notice of References Cited</b>	Application/Control No. 09/845,581	Applicant(s)/Patent Under Reexamination ANDO ET AL.	
	Examiner Andrew Lee	Art Unit 2663	Page 1 of 1

**U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-6,075,776	06-2000	Tanimoto et al.	370/254
	B	US-6,345,299	02-2002	Segal, Edward Robert	709/244
	C	US-6,609,154	08-2003	Fuh et al.	709/225
	D	US-6,799,177	09-2004	Fai et al.	709/217
	E	US-5,623,601	04-1997	Vu, Hung T.	713/201
	F	US-6,754,832	06-2004	Godwin et al.	713/201
	G	US-6,693,878	02-2004	Daruwalla et al.	370/392
	H	US-6,172,991	01-2001	Mori, Naoki	370/389
	I	US-5,905,859	05-1999	Holloway et al.	713/201
	J	US-6,449,251	09-2002	Awadallah et al.	370/465
	K	US-6,708,218	03-2004	Ellington et al.	709/230
	L	US-6,738,909	05-2004	Cheng et al.	709/223
	M	US-6,792,461	09-2004	Hericourt, Olivier	370/230

**FOREIGN PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	O					
	P					
	Q					
	R					
	S					
	T					

**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	
	V	
	W	
	X	

\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.